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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/747,654	12/30/2003	Hans Butler	081468-0307455	1582
909 7590 05/11/2007 PILLSBURY WINTHROP SHAW PITTMAN, LLP P.O. BOX 10500			EXAMINER	
			CONNOLLY, PATRICK J	
MCLEAN, VA 22102			ART UNIT	PAPER NUMBER
			2877	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
	10/747,654	BUTLER, HANS			
Office Action Summary	Examiner	Art Unit			
	Patrick J. Connolly	2877			
The MAILING DATE of this communication app	pears on the cover sheet with the c	orrespondence address			
Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPL' WHICHEVER IS LONGER, FROM THE MAILING D. Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be timwill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 22 Ja	anuary 2007.				
2a) This action is FINAL . 2b) ☐ This	This action is FINAL . 2b)⊠ This action is non-final.				
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is				
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) ⊠ Claim(s) 1-28 is/are pending in the application. 4a) Of the above claim(s) is/are withdraw 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-28 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/o	wn from consideration.				
Application Papers					
9) ☐ The specification is objected to by the Examine 10) ☑ The drawing(s) filed on 30 December 2003 is/a Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) ☐ The oath or declaration is objected to by the Ex	re: a) \square accepted or b) \square objected drawing(s) be held in abeyance. See tion is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 01.03.2007.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te			

DETAILED ACTION

Response to Arguments

Applicant's arguments with respect to claims 1-28 have been considered but are moot in view of the new ground(s) of rejection. Further search and consideration has produced new prior art that has been applied below.

Applicant's arguments, see Remarks, filed January 22, 2007, with respect to non-statutory subject matter have been fully considered and are persuasive. The rejection of claims 22-28 on grounds of failure to claim a tangible result has been withdrawn.

Claim Rejections - 35 USC § 102

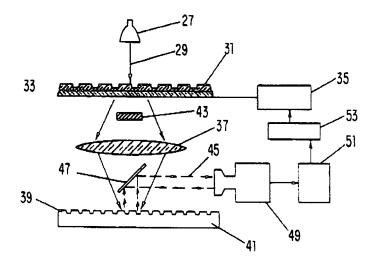
The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-6, 14, 16, 18, 19 and 21-23 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by U.S. Patent No. 5,343,292 to Brueck et al (hereafter Brueck).

As to claims 1, 18 and 21, Brueck discloses a method and apparatus for alignment of lithographic features including (see Figure 3 below):



a first object (33) having a first pattern (31;

a second object (41) having a second pattern (39) corresponding to the first pattern; a projection system (27, 37) configured to project an image of the first pattern onto the second pattern; and

a detector (49) configured to measure an amplitude of at least one order of a diffraction pattern resulting from an interference of the second pattern and the projected image (see column 2, lines 20-36).

As to **claim 2**, Brueck discloses longitudinal structures oriented in two different directions (see Figure 4, also column 4: lines 11-21).

As to **claim 3**, Brueck discloses alternating structures (see Figure 4, also column 4: lines 11-21).

As to claim 4, Brueck discloses photodetectors (49).

As to **claims 5, 6 and 19**, Brueck discloses measuring the amplitude in synchronism with illumination and positioning of the wafers (see Figure above).

As to **claim 14**, Brueck discloses a detector located outside of the projected image (see Figure above).

As to **claim 16**, Brueck discloses measuring at different relative positions (see for example bottom of column 3).

As to **claim 22**, Brueck discloses a beam of radiation (29).

As to **claim 23**, Brueck discloses exposing the substrate with a pattern based on positioning (see for example abstract).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 7, 15, 20 and 24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Brueck.

As to **claims 7 and 24**, Brueck is silent regarding the depth of the phase grating in the second pattern.

It is well known in the art that the peak phase modulating will occur in gratings when the grating depth is near ¼ the wavelength of the light source being modulated (see for example, the gratings of U.S. Patent No. 5,225,039 to Ohguri. These gratings are for use in DFB lasers, but the advantage of peak modulation at that grating depth is still taught).

The Examiner takes Official Notice of the fact that it would be obvious to optimize the modulation implemented by the patterns of Brueck by using gratings with depths of near or at 1/4

wavelength of the light source so as to achieve strong amplitude measurements for better positioning measurements.

As to **claims 15 and 20**, although Brueck teaches overlay measurement based on the corresponding relative displacement of the two patterns, Brueck is silent with respect to calibration procedure.

The Examiner takes Official Notice of the fact that it is well known in the art to calibrate overlay apparatuses based upon relative displacement measurements of overlay patterns so as to achieve more accurate measurements and exposures in the lithography process.

It would have been obvious to one of ordinary skill in the art at the time of invention to calibrate the apparatus of Brueck based upon a measurement of the relative displacement of the overlay patterns in order to improve accuracy and efficiency in the lithographic exposure process.

Claims 8-13 and 25-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Brueck as applied to claims 1-7 and 14-24 above, and further in view of U.S. Patent No. 5,754,341 to Takata et al (hereafter Takata).

As to **claims 8-13** and **25-28**, Brueck teaches measuring *at least* the +/- 1 order of diffraction. Brueck does not explicitly teach measuring even orders of diffraction (see column 3: lines 35-51).

Takata teaches phase gratings for use in optical encoders including measuring even and odd orders of diffraction (see Figure 4, column 11) based on the relative sensitivities of the orders with regard to direction of movement.

It would have been obvious to one of ordinary skill in the art at the time of invention to detect multiple orders of diffraction, including both even and odd orders, with the apparatus and method of Brueck as taught by Takata so as to achieve the sensitivity desired with regard to direction of movement.

"Several facts have been relied upon from the personal knowledge of the examiner about which the examiner took Official Notice. Applicant must seasonably challenge well known statements and statements based on personal knowledge when they are made by the Board of Patent Appeals and Interferences. In re Selmi, 156 F.2d 96, 70 USPQ 197 (CCPA 1946); In re Fischer, 125 F.2d 725, 52 USPQ 473 (CCPA 1942). See also In re Boon, 439 F.2d 724, 169 USPQ 231 (CCPA 1971) (a challenge to the taking of judicial notice must contain adequate information or argument to create on its face a reasonable doubt regarding the circumstances justifying the judicial notice). If applicant does not seasonably traverse the well-known statement during examination, then the object of the well known statement is taken to be admitted prior art. In re Chevenard, 139 F.2d 71, 60 USPQ 239 (CCPA 1943). A seasonable challenge constitutes a demand for evidence made as soon as practicable during prosecution. Thus, applicant is charged with rebutting the well-known statement in the **next reply** after the Office action in which the well known statement was made."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Patrick J. Connolly whose telephone number is 571.272.2412. The examiner can normally be reached on 9:00 am - 7:00 pm Monday-Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Gregory J. Toatley, Jr. can be reached on 571.272.2800 ext. 77. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Fatile Connolly 04.23.2007